

## United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE
United States Patent and Trademark Office
Address: COMMISSIONER OF PATENTS AND TRADEMARKS
Washington, D.C. 20221
www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
09/607,219	06/30/2000	Atsushi Kanda	15.18/5053	8200
24033	7590 03/31/2003			
KONRAD RAYNES VICTOR & MANN, LLP			EXAMINER	
SUITE 210	BEVERLY DRIVE	QUACH, TUAN N		
BEVERLY HILLS, CA 90212			ART UNIT	PAPER NUMBER
			2814	
			DATE MAILED: 03/31/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Applicati n N .	Applicant(s)				
<b>v</b>	09/607,219	KANDA, ATSUSHI				
Offic Acti n Summary	Examin r	Art Unit				
	Tuan Quach	2814				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Peri df r Reply						
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.  - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.  - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).  - Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).  Status						
1) Responsive to communication(s) filed on <u>07 F</u>	ebruary 2003 .					
2a) ☐ This action is <b>FINAL</b> . 2b) ☑ Thi	s action is non-final.					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.  Disposition of Claims						
4) Claim(s) 48,49 and 52-74 is/are pending in the application.						
<del>/</del>						
4a) Of the above claim(s) is/are withdrawn from consideration.  5) ☐ Claim(s) is/are allowed.						
6) Claim(s) 48,49 and 52-74 is/are rejected.						
7) Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction and/or election requirement.  Application Papers						
9)☐ The specification is objected to by the Examiner.						
10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
11)☐ The proposed drawing correction filed on is: a)☐ approved b)☐ disapproved by the Examiner.						
If approved, corrected drawings are required in reply to this Office action.						
12)☐ The oath or declaration is objected to by the Examiner.						
Priority under 35 U.S.C. §§ 119 and 120						
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a)⊠ All b)□ Some * c)□ None of:						
1. Certified copies of the priority documents	s have been received.					
2. Certified copies of the priority documents	have been received in Applicati	on No				
<ul> <li>3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>						
14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).						
a) ☐ The translation of the foreign language provisional application has been received. 15)☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.						
Attachment(s)						
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s)						
J.S. Patent and Trademark Office						

Application/Control Number: 09/607,219

Art Unit: 2814

## **DETAILED ACTION**

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

For convenience, "et al." is omitted, e.g., Chen for Chen et al.

Claims 48, 49, 52-74 are rejected under 35 U.S.C. 103(a) as being unpatentable over taken with Bach taken with Chen and Hall.

Bach teaches forming dielectric layers 18 and 20 of oxide and nitride on metal line 16/17, forming photoresist 24 thereon, etching the dielectric layers to form tapered openings. The use of fluorine compound such as CF<sub>4</sub> or SF<sub>6</sub> as etchant and the inclusion of oxygen are also taught wherein such oxygen addition serves to control the tapered shape. See column 4 line 61 to column 5 line 23, column 7 line 1-3, column 8 lines 11-67. Back does not recite the identical language of pad.

Chen teaches pad 16, passivation 20 comprising silicon oxide 20A and silicon nitride 20B, forming photoresist mask 22, dry etching the passivation 20 to the pad 16, including isotropic etching and anisotropic etching to prevent erosion of photoresist to prevent penetration and attach of passivation over wiring lines. The use of fluorine containing etchant and fluorocarbon etchant is also taught. See the abstract, Fig. 4, column 3 line 40 to column 5 line 32.

Hall also teaches the provision of pad 22 interconnect 24 from interconnecting layer 12, which is formed from the interconnect layer followed by passivation layer 42

Application/Control Number: 09/607,219

Art Unit: 2814

including oxide 422 and nitride layer 424 and the etching therethrough using dry etching including the use of suitable fluorine containing materials carbon tetrafluoride. The use of carbon tetrafluoride and oxygen is also tuaght. See column 2 line 7 to column 3 line 27.

It would have been obvious to one skilled in practicing Bach to have employed the metal line to be the aluminum pad since such corresponds to conventional language and structure for such aluminum structure as pad as evidenced by Chen or Hall wherein such pad application and opening thereto can be obtained. The use of isotropic etching would have been obvious and advantageous as taught by Chen wherein penetration and attack of the passivation over the wiring lines can be obviated. It would have been obvious and would have been within the purview of one skilled in the art to have employed the desired profiles including a desired angle the upper layer and a more steeping angle for the lower layer if desired as evidenced in Chen, to have optimized the appropriate distance to improve device packing. Conversely, although Chen recites NF<sub>3</sub> as etchant of the nitride, the use of CF<sub>4</sub> as alternative fluorine containing materials would have been obvious to one skilled in the art as evidenced by Hall, column 3 lines 18-23, including its oxygen inclusion as delineated in Hall, column 2 line 66 and in Bach as delineated above evidencing the interchangeability of such fluorine containing sources including the use of oxygen. It would have been conventional and obvious to have effected continuous etching given the teachings delineated above wherein no discontinuation is required or so that such discontinuation may be minimized. The completion of the connection including the provision of a bump electrode including a

Application/Control Number: 09/607,219

Art Unit: 2814

barrier on the exposed bonding pad is well known in the art and thus would have been obvious.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to examiner Quach whose telephone number is 703-308-1096. The examiner can normally be reached on M - F from 9 to 5.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor Wael Fahmy can be reached on (703) 308-4918. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9318 (Before Final) and (703) 872-9319 (After Final).

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

Tuan Quach Primary Examinar